

Docket No. N1085-00040
 Inventor: Ming-Shuoh Liang et al.
 "A Method Of Providing Via In A Multilayer Semiconductor Device"
 Sheet 1 of 6

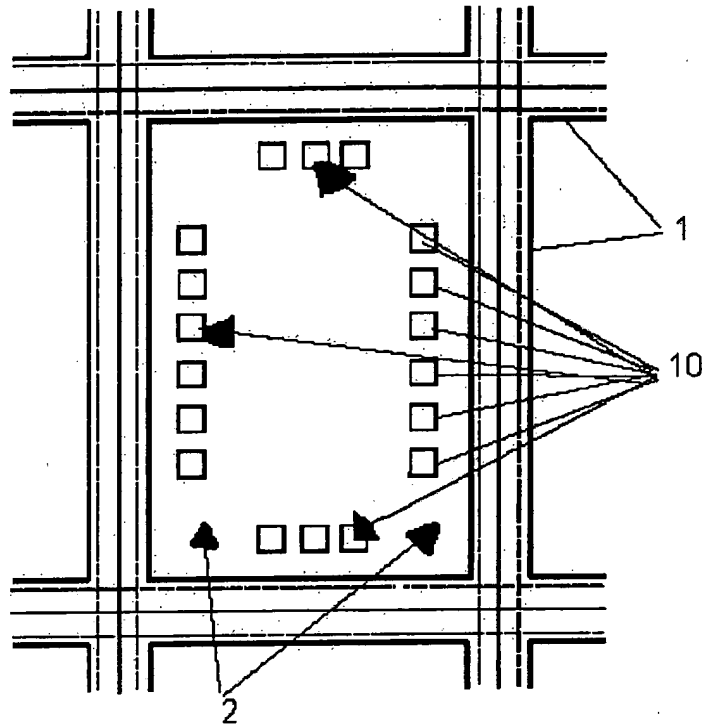


FIG. 1 (PRIOR ART)

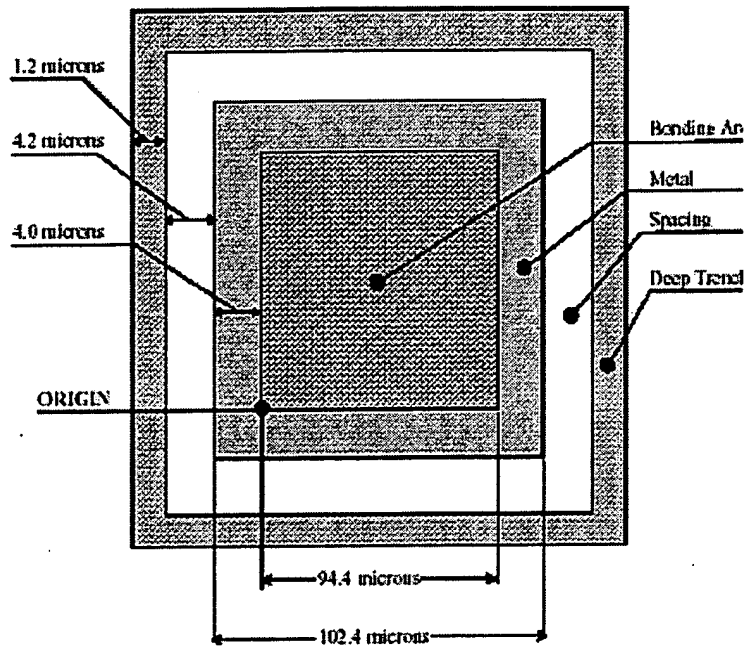


FIG. 2a (PRIOR ART)

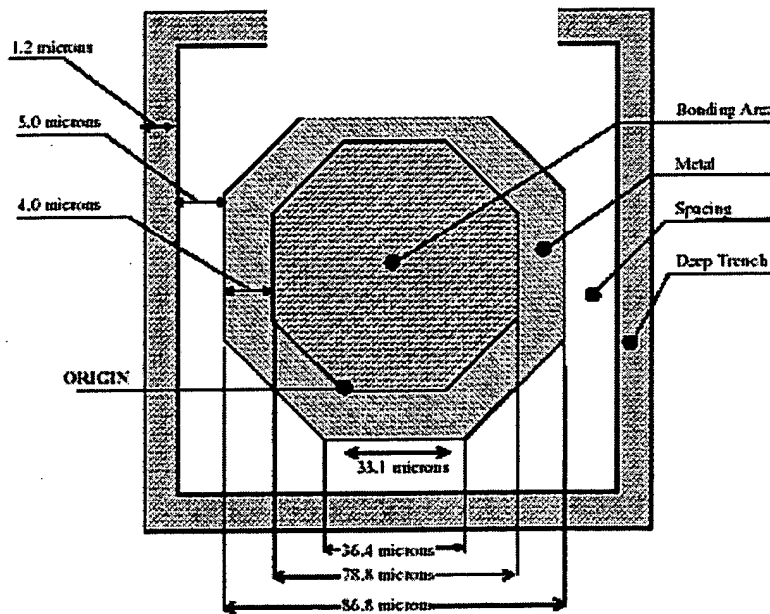


FIG. 2b (PRIOR ART)

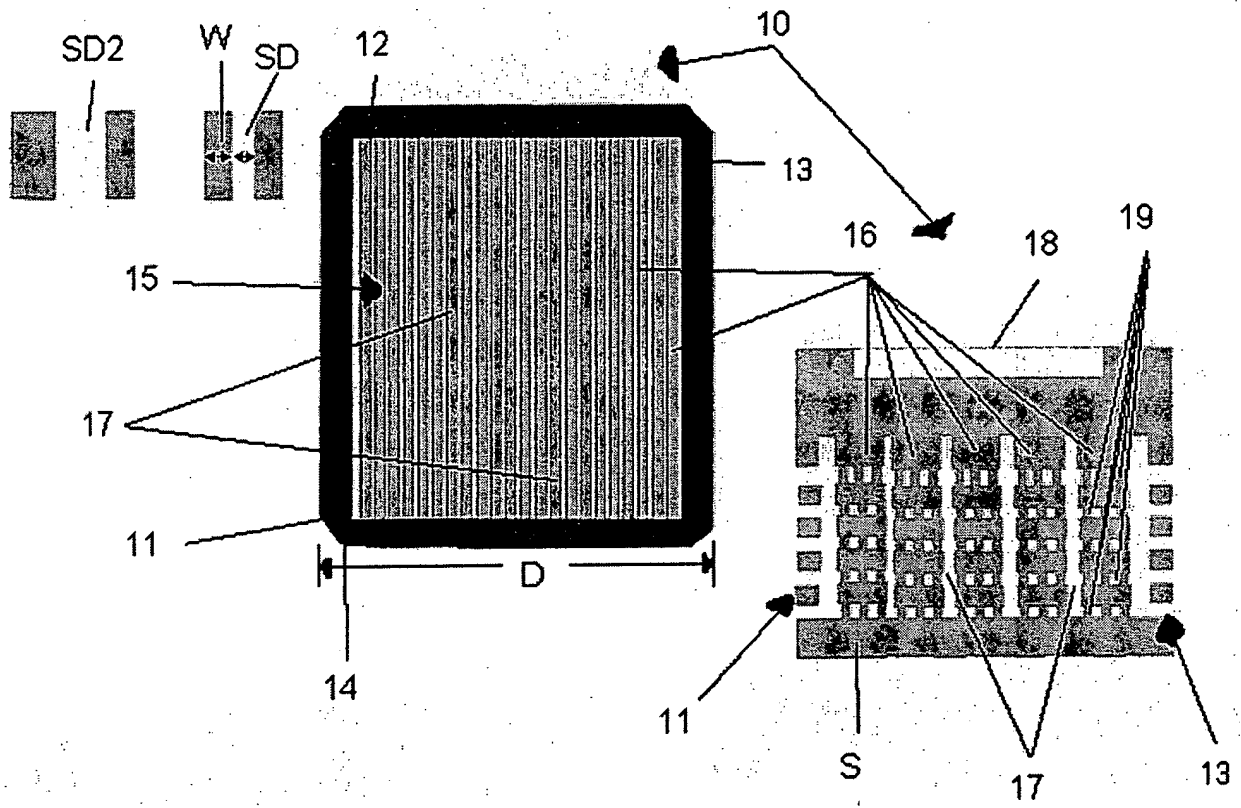


FIG. 3a

FIG. 3b

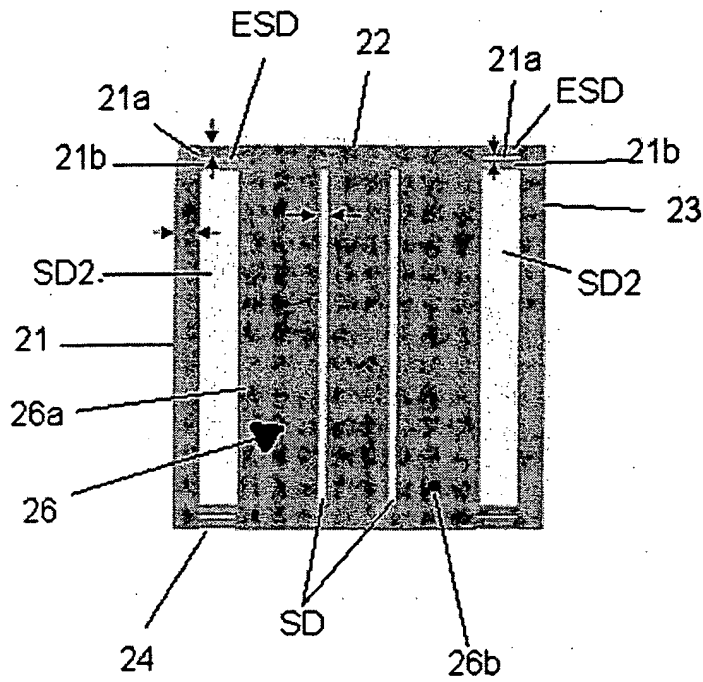


FIG. 4a

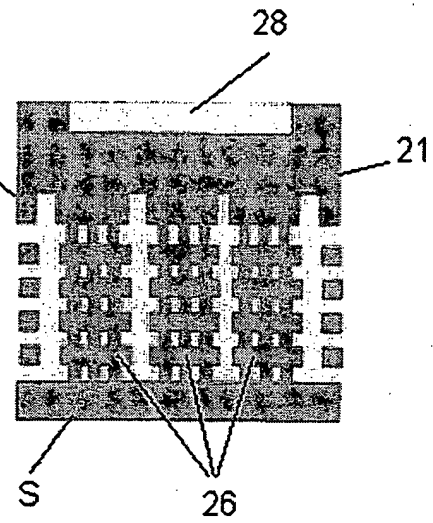


FIG. 4b

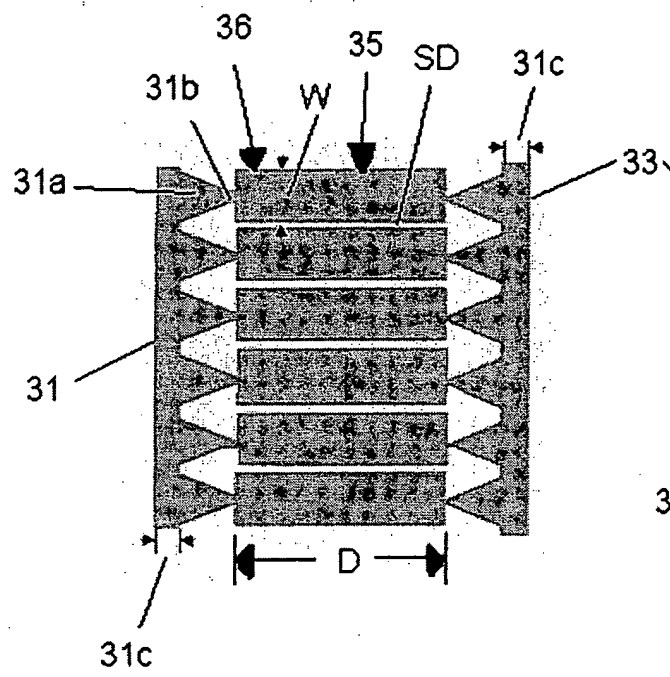


FIG. 5a

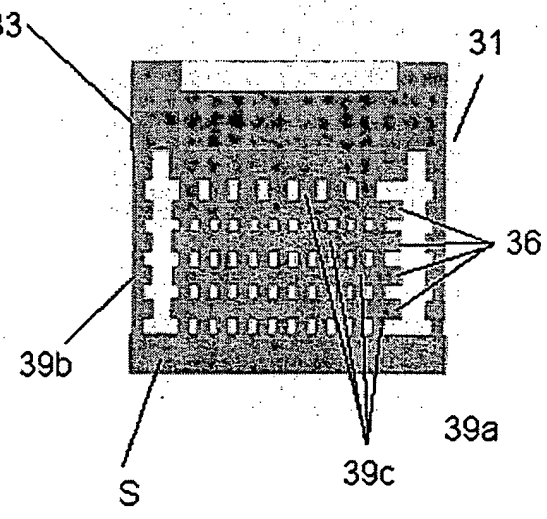


FIG. 5b

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